



晶银新材
iSilver Materials

Research and development of low temperature pastes for silicon heterojunction solar cells

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苏州晶银新材料科技有限公司
Suzhou iSilver Materials Co., Ltd.

Part **1**

Company profile



- Suzhou isilver Materials was founded in 2011.
- A high-tech enterprise engaged in the field of new energy and semiconductor.
- Purchased and listed by Suzhou Good-ark (SZ002079) in 2020.

Focus on photovoltaic and semiconductor electronic materials

Core technology system of independent innovation

> 27 acres

Area

> 1000 tons

Plant capacity

> 200 tons

Capacity of LTP

> 160 people

Employee

> 10 million yuan

Per capita output value

Part **2**

The direction of low temperature pastes

Three difficulties:

➤ **High consumption——1.5-2 times higher than that of the high temperature paste**

18-22mg/W on regular production line of heterojunction cells , compared with PERC cells (10-12mg/w)

➤ **Low printing speed——Low productivity**

- the printing speed of 300-350mm/s on production line, compared with PERC cell (450-500mm/s)

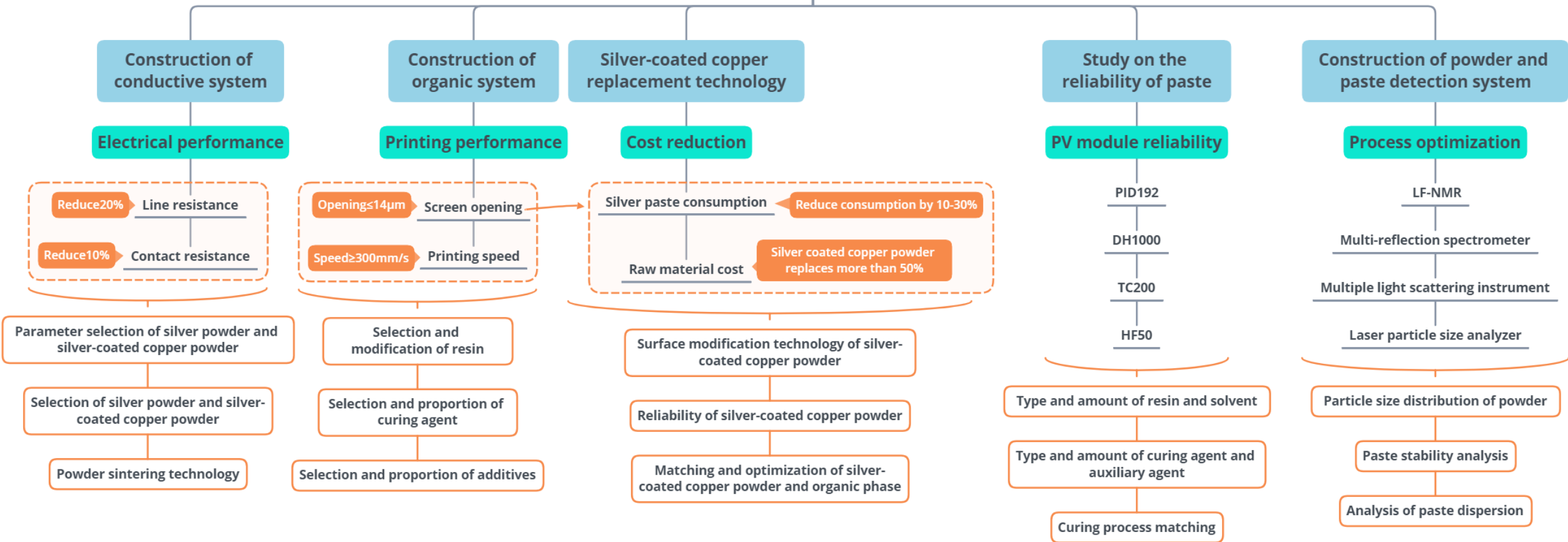
➤ **Wider grid —— Heavy use of paste,Low efficiency**

- About 35-40 μ m in width on production line, compared with PERC cell (20-25 μ m)

R&D roadmap of low temperature paste



Heterojunction low temperature paste



R&D direction of low temperature paste



Third generation paste

Fourth generation paste

Dual printing
Busbar

Dual printing
Finger

Dual printing
Finger

Dual printing
Alloyed Busbar

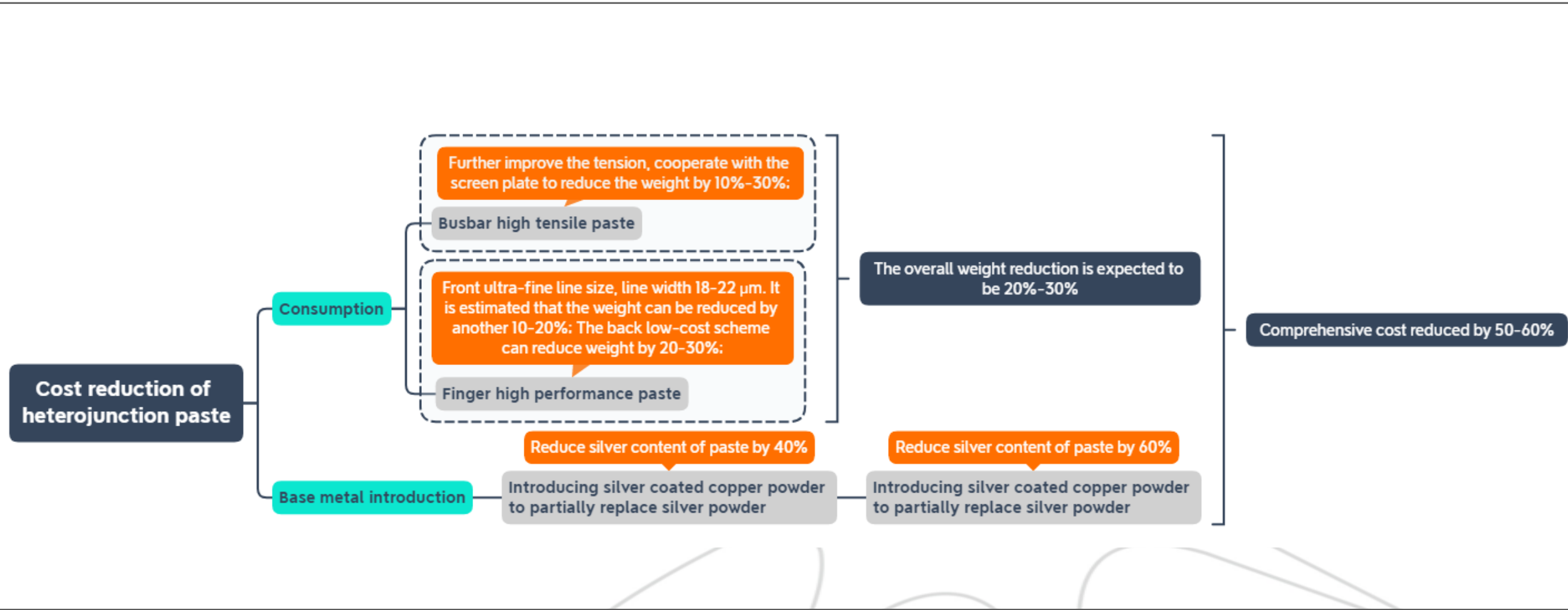
Dual printing
Finger with low-
cost model

Dual printing
Finger with silver-
coated copper

Dual printing
Finger with silver-
coated copper

Category	HC639-ZX	HC649-H	HC689-H	HSC639-Z	HD689-G	HAC639-T	HAC689-T
Silver content (%)	92-93	92-93	92-93	60-70	89-91	43-50	30-40
Volume resistivity ($\mu\Omega\cdot\text{cm}$)	6.0-7.0	5.0-6.0	5.5-6.5	8.0-9.5	5.0-6.0	7.0-8.5	7.5-9.0
Viscosity (Pa•s)	250-300	250-300	≥ 350	≥ 350	≥ 350	≥ 350	≥ 350
Printing speed (mm/s)	—	≥ 21	≥ 12	—	≥ 18	≥ 18	≥ 16
Pulling strength (N/mm)	≥ 2.0	—	—	≥ 2.0	—	—	—

Cost reduction roadmap of low temperature paste



Part **3**

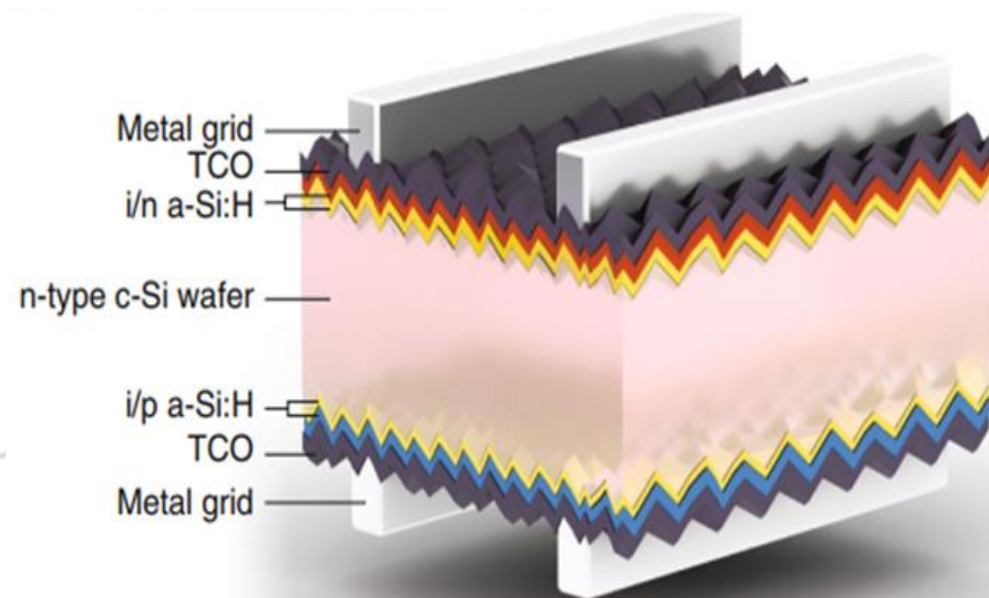
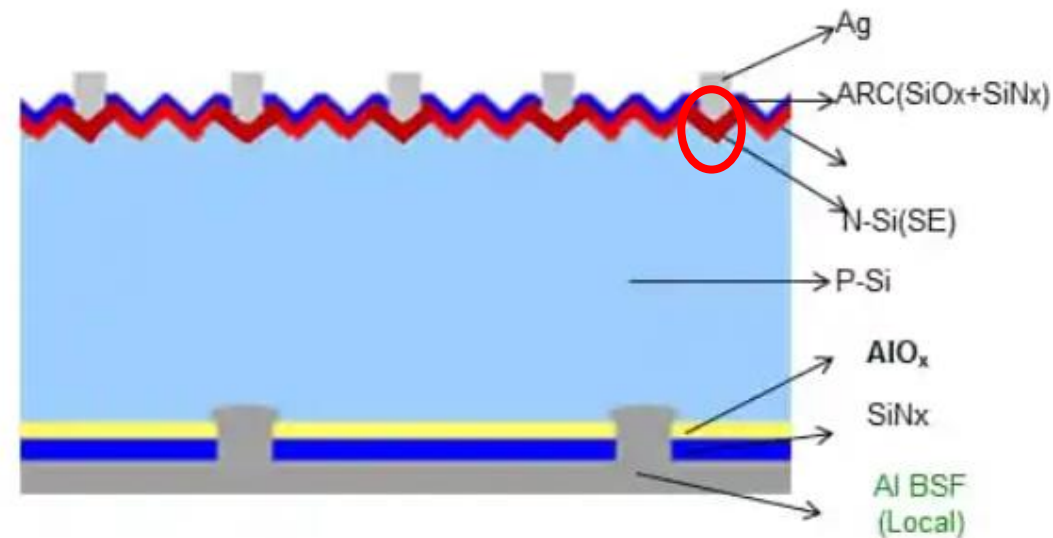
High conductivity technology of low temperature pastes

Difference between high and low temperature paste



Different point:

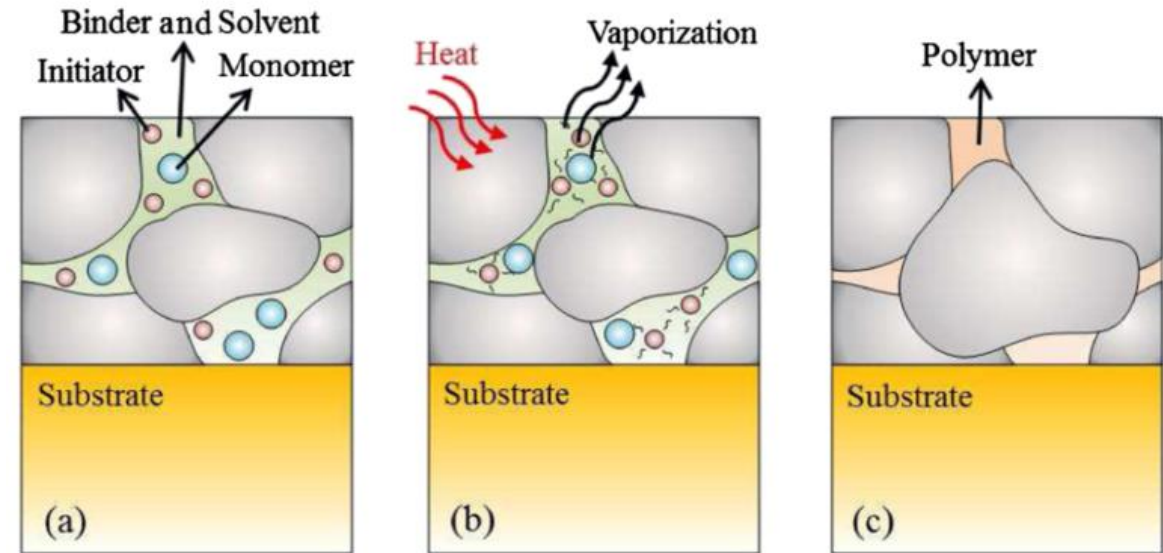
High temperature front silver paste	Difference	Heterojunction paste
700-800°C	Temperature	170-200°C
Contact with <i>p-n</i> junction, burn through anti - reflection layer	Contact theory	Not in direct contact with <i>p-n</i> junction, but contact with TCO
Spherical silver powder, flake glass powder, organic component	Composition	Flake, spherical silver powder, organic component
mainly plays a printing role	Organic component	Printing and adhesion
Start early, mature	Development situation	Start late, developing



Study on the conductive theory of low temperature paste

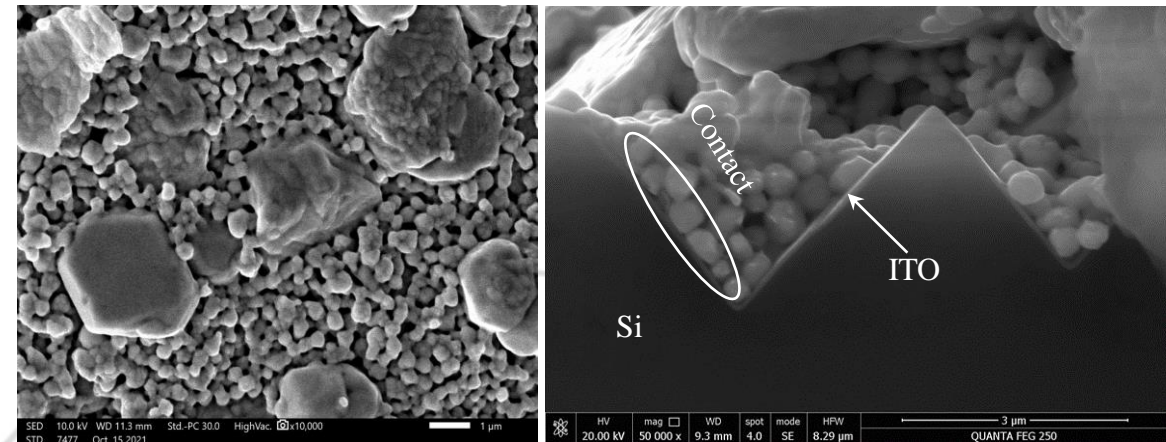
Conductive theory and Ohmic contact of low temperature paste:

- ✓ After baking, the solvent in the paste evaporates, the resin is crosslinked and solidified, and there is resin on the surface of the conductive powder, which cannot directly transfer electrons.
- ✓ Conduction theory: electron transmission mainly through seepage effect and tunneling effect.



Research content

- Study on ohmic contact mechanism between low temperature paste and TCO layer.
- Optimize conductive phase and organic phase, improve the densification of the paste after curing, enhance the contact, and reduce the bulk resistance and contact resistance through the nano size effect.

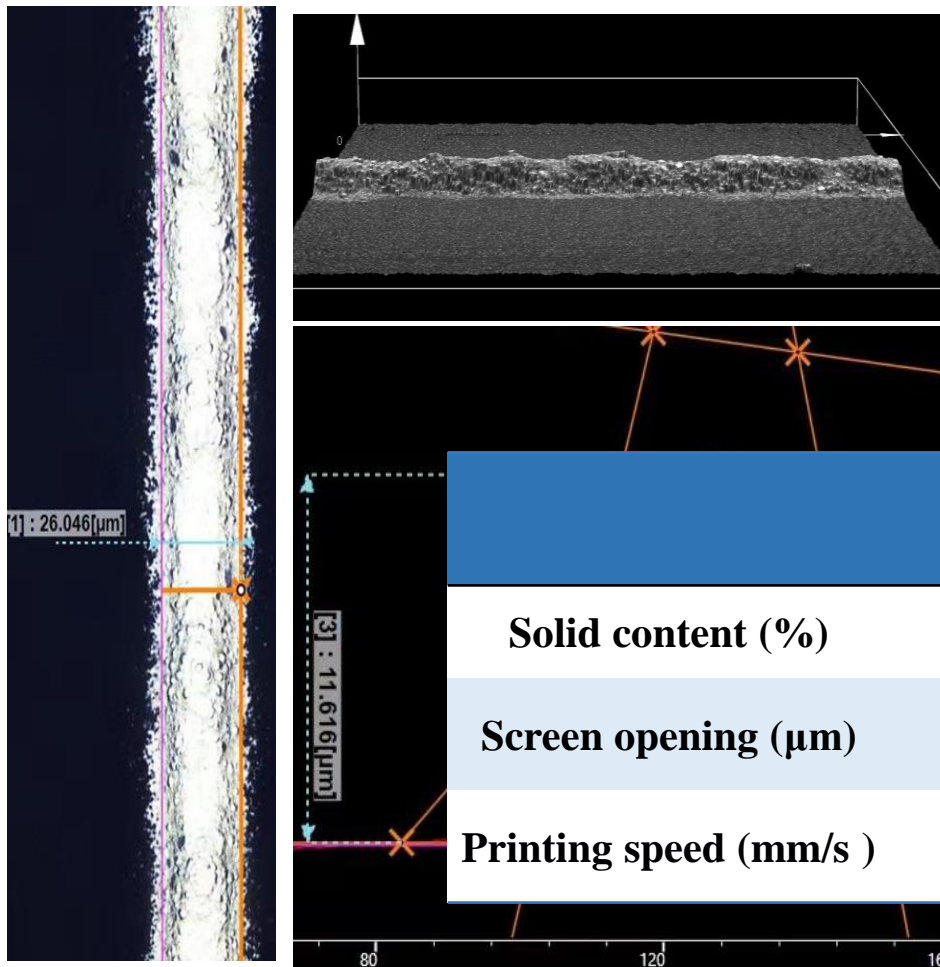


Part **4**

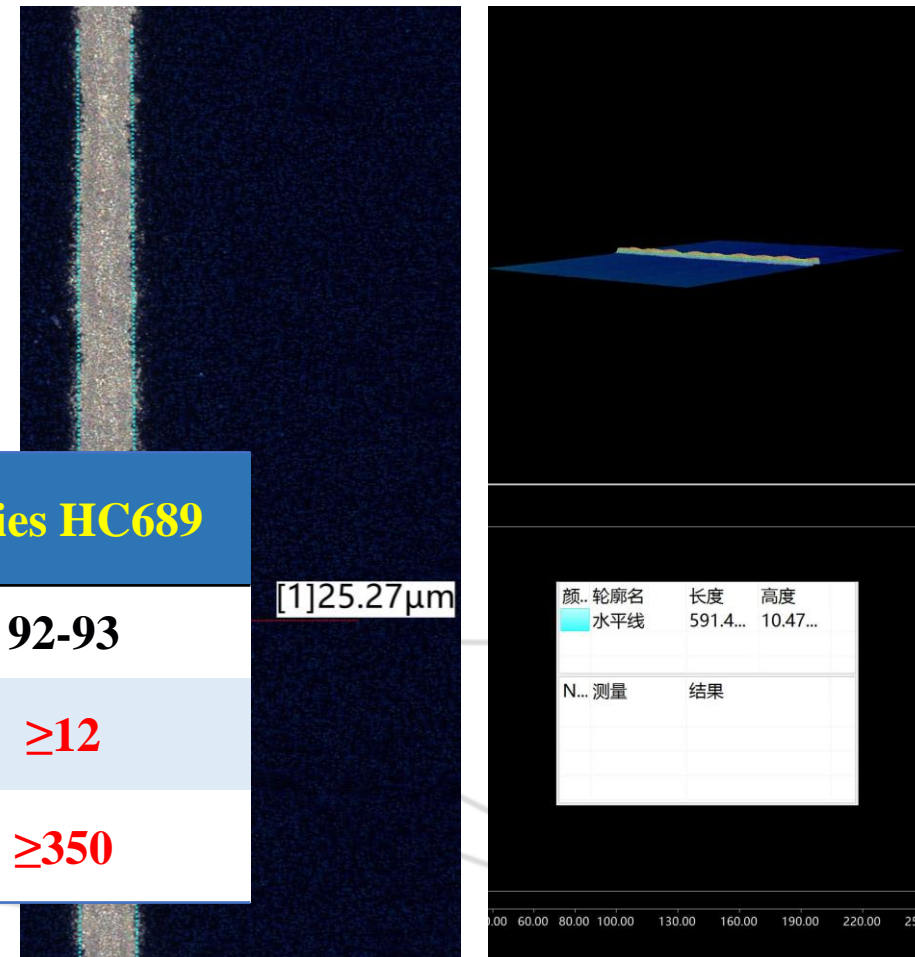
Ultra-fine printing properties of low temperature paste

The new generation of front pure silver paste

480/11 PI knotless/opening 17 μ m



520/11 PI knotless/opening 12 μ m



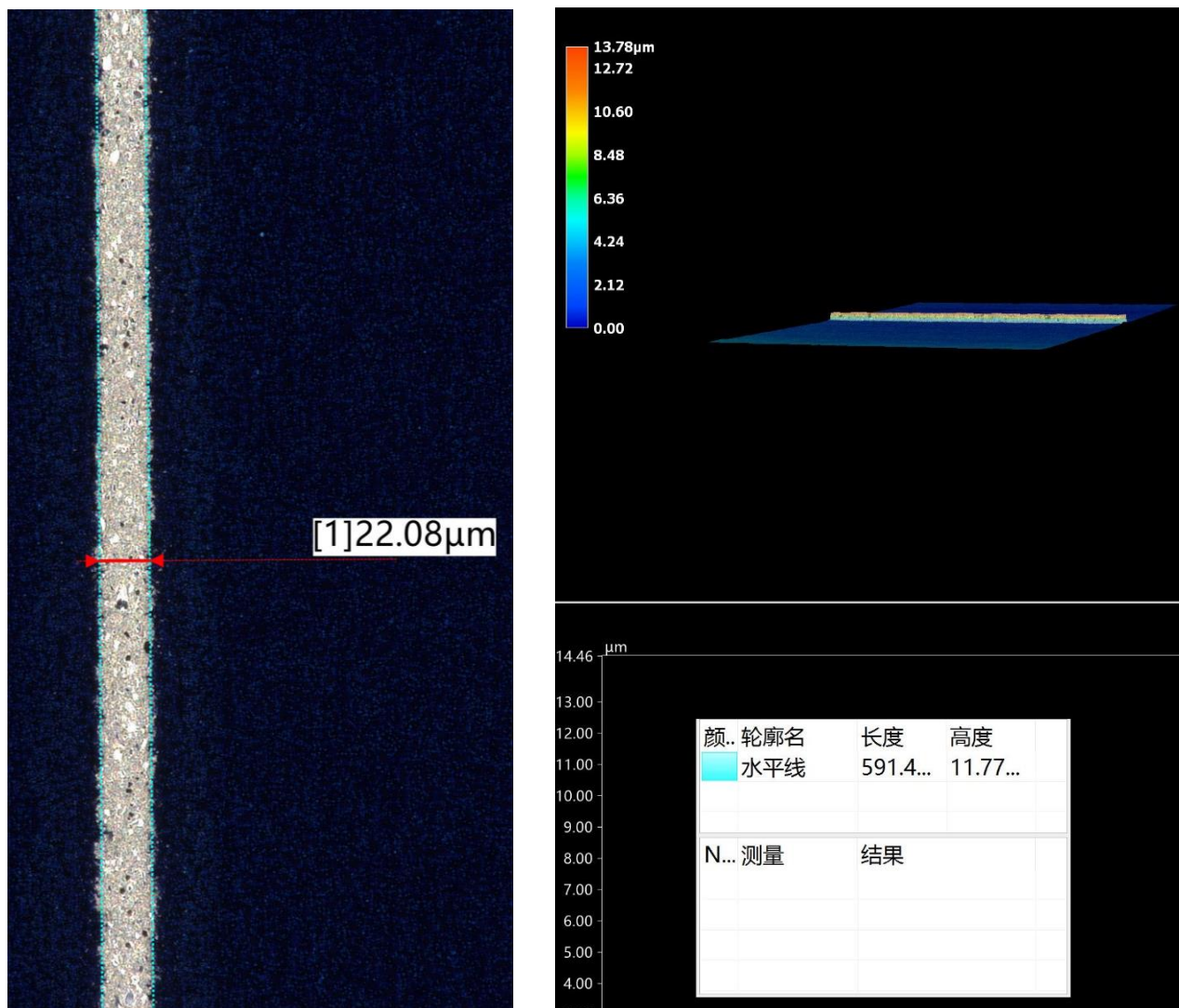
Second generation front fine grid
(in development)



	Series HC649	Series HC689
Solid content (%)	92-93	92-93
Screen opening (μ m)	≥ 22	≥ 12
Printing speed (mm/s)	230-280	≥ 350

Fine line scheme paste application

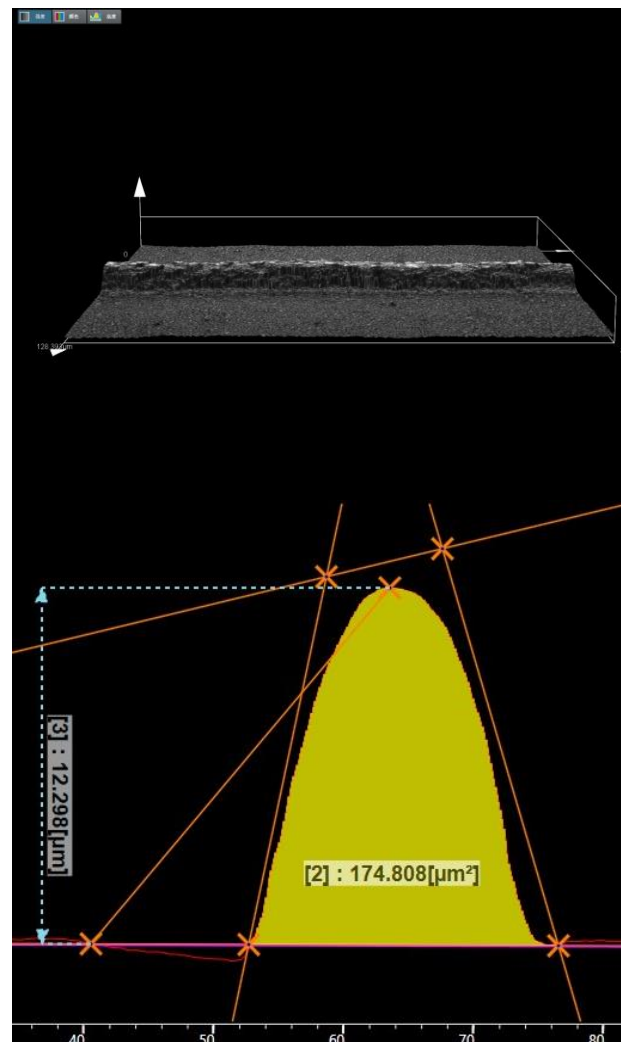
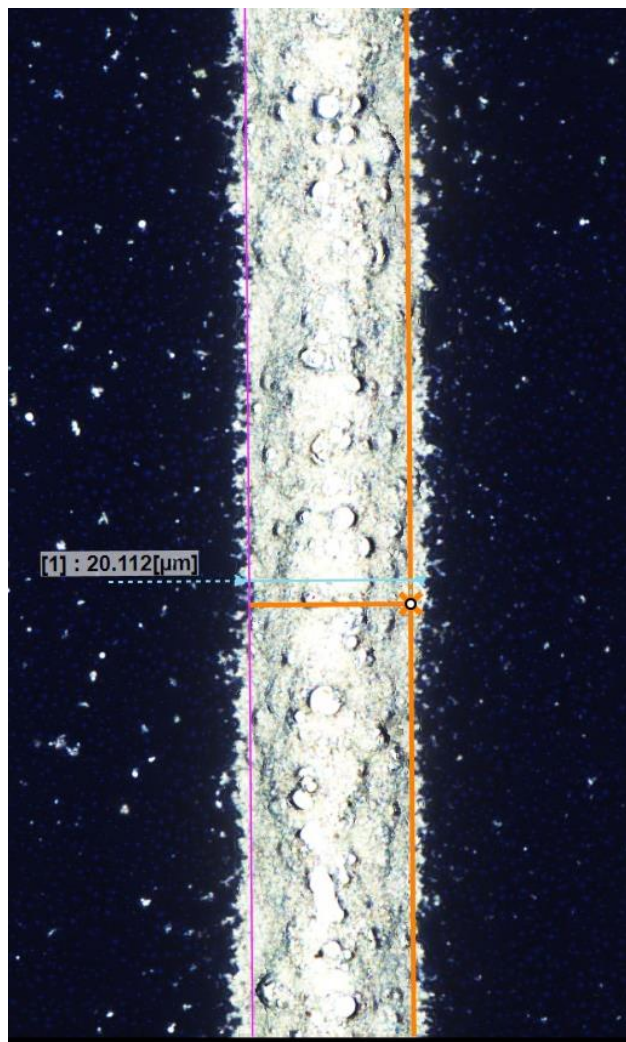
◆ HC series paste matching metal stencil printing:



- **Full-open stencil** is made of stainless steel with high strength, wear resistance and corrosion resistance as the main material.
- **Full-open stencil** adopts advanced laser technology for full open cutting of stainless steel sheet, and adopts special process to treat the steel plate, so that its opening is smoother and flat, and the line type is better.
- At present, the fine grid printing with the width of **22-25μm** can be achieved.

Fine line scheme paste application

◆ HJ series paste matching laser transfer :

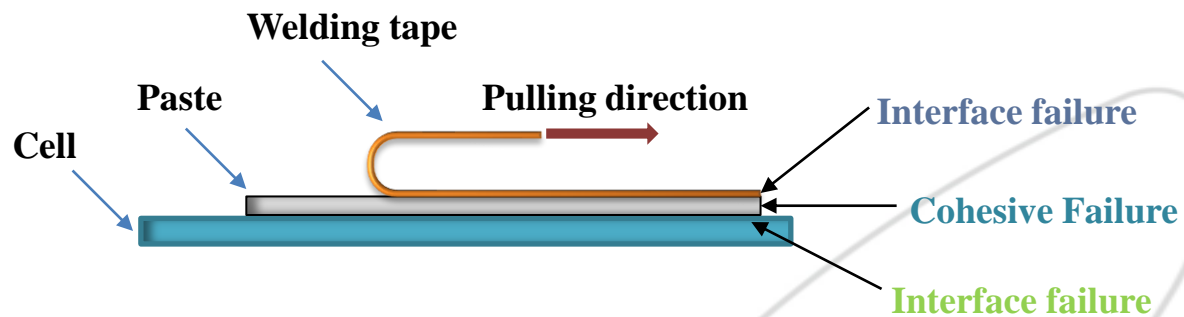
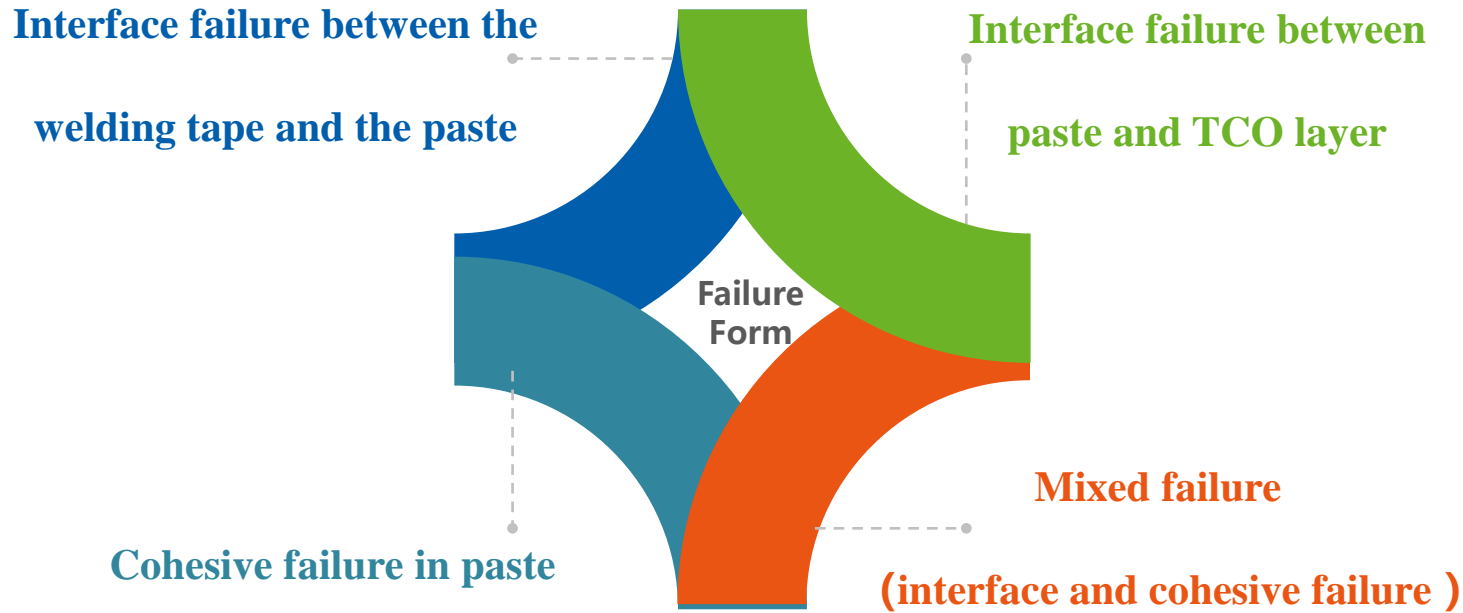


- **Laser transfer equipment** uses a special scraper to press the heterojunction low-temperature paste into a special bearing film, and then uses a special laser head and its scanning transfer process, combined with a high-precision CCD system, to accurately transfer the paste from the bearing film to the silicon wafer.
- At present, extremely fine grid line printing with width as low as **20μm** has been achieved.

Part **5**

Welding tensile properties of low temperature paste

Pull-out failure form of low temperature pastes

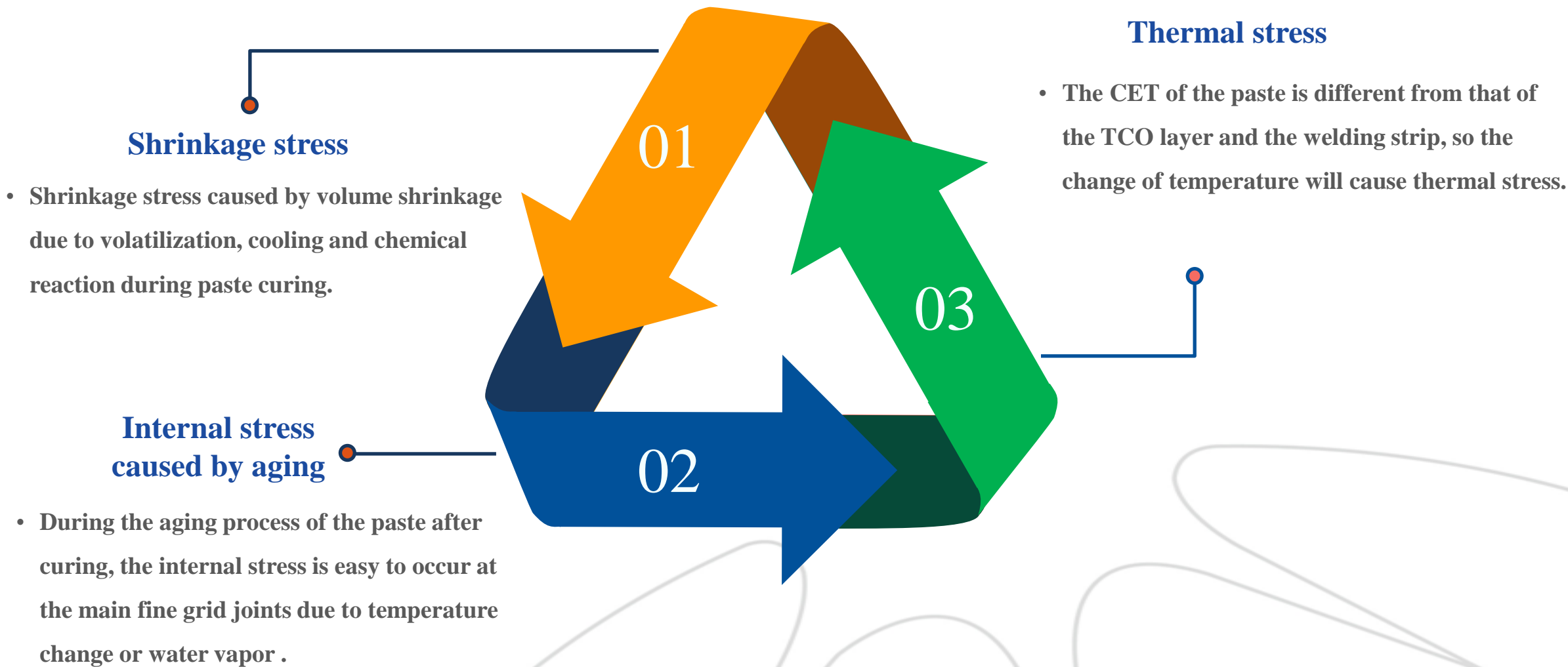


The failure of paste itself is the ideal failure form, that is, 100% cohesive failure, because this failure can obtain the maximum bonding strength when the material is bonded.

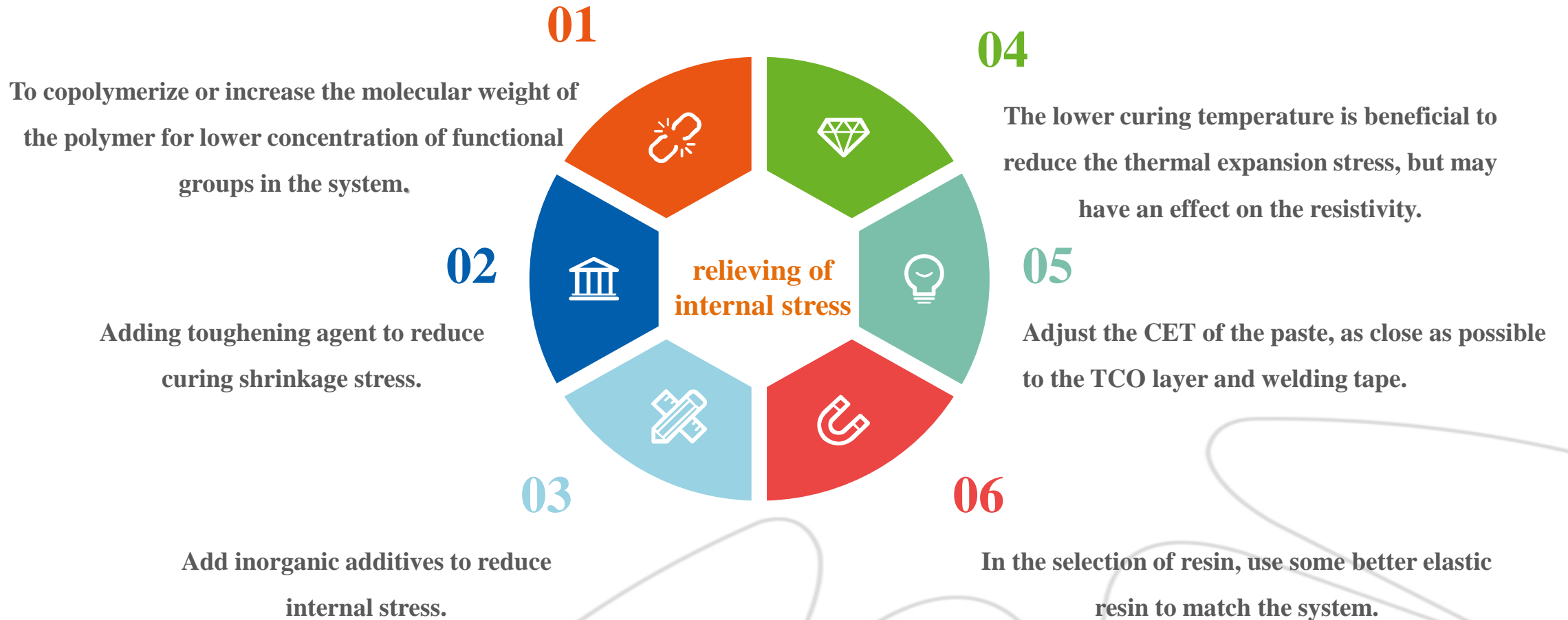


Bonding failure occurs at the weakest point and may not always occur at the interface. This indicates that the bonding strength is not only related to the force between the paste, the welding tape and the TCO layer, but also to the intermolecular force of the polymer resin. The chemical structure and aggregation state of polymer molecules will greatly affect the bonding strength.

The internal stress of low temperature paste



The internal stress of low temperature paste



Low silver alloy busbar paste (in development)

	HC639-ZX	HSC639-Z
Silver content (%)	92-93	70-75
Volume resistivity ($\mu\Omega\cdot\text{cm}$)	5.5-6.0	8.0-9.5
Busbar tension (N/mm)	≥ 2.2	≥ 2.2

- Preliminary test results: compared with the pure silver busbar paste, the efficiency is equal, and the tension of hand welding has no difference.
- Pilot and reliability tests are following.
- In this scheme without copper on busbar, the density of alloy powder is relatively low, and the wet weight decreases significantly.

Part **6**

Study on low temperature silver coated copper paste

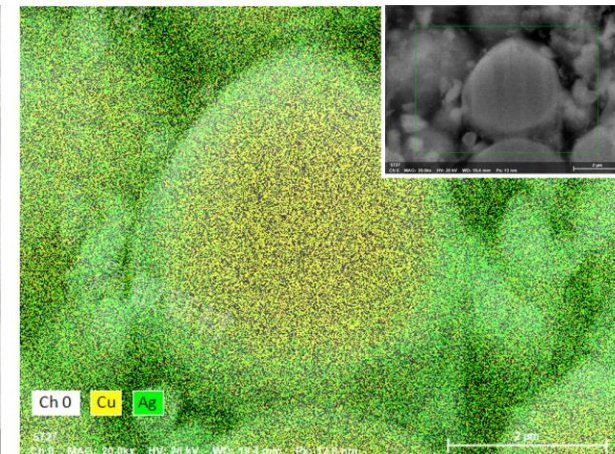
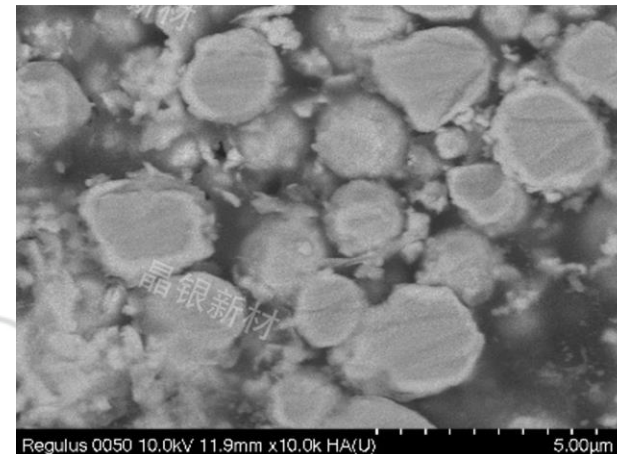
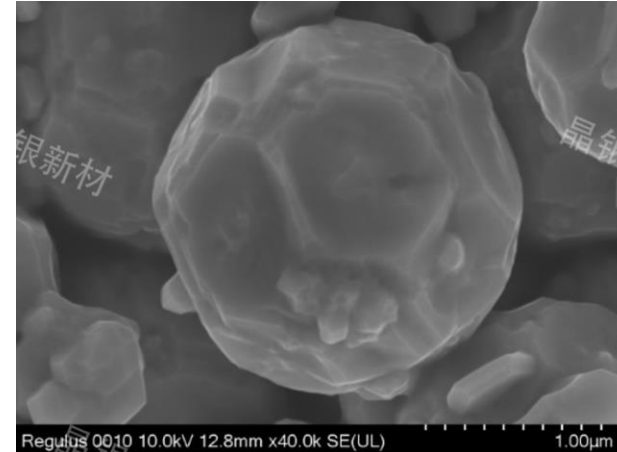
Core material - silver coated copper powder

Current situation :

- ✓ The main component of the plating solution is composed of silver nitrate solution. The electronegativity of copper is higher than that of silver, and a replacement reaction can occur. Free silver ions undergo a replacement and reduction reaction on the surface of copper powder to form silver coating.
- ✓ At present, most processes often use complexing agents to chelate free silver ions, increasing the complexing constant of silver ions and ensuring the stability of the plating solution during the metal coating process.

➤ Production process:

At present, electroless plating technology can ensure the uniformity, coating rate and stability of the coating.



Research status of silver coated copper paste

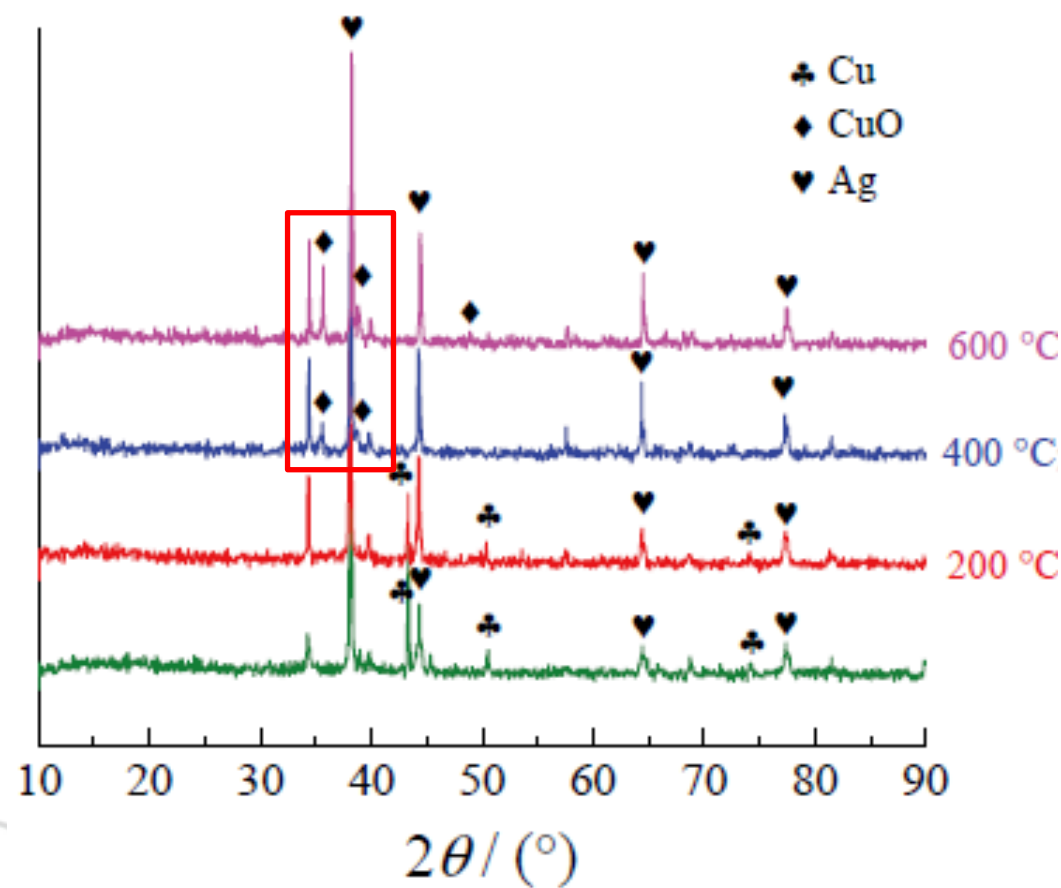


Oxidation resistance :

- ✓ After calcination at different temperatures, the characteristic peak of Cu weakens obviously or even disappears.
- ✓ There is no CuO characteristic peak in the silver-coated copper powder calcined at 200 °C, indicating that the powder is not oxidized or the oxidation degree is very low.
- ✓ After calcination at 400 °C and 600 °C, the (-111), (111) and (-202) crystal faces of CuO appear at 2θ of 35.5° , 38.7° and 48.7° , respectively.

➤ Characteristic:

Only can only be used in low temperature paste, high temperature silver layer will melt resulting in exposed copper.

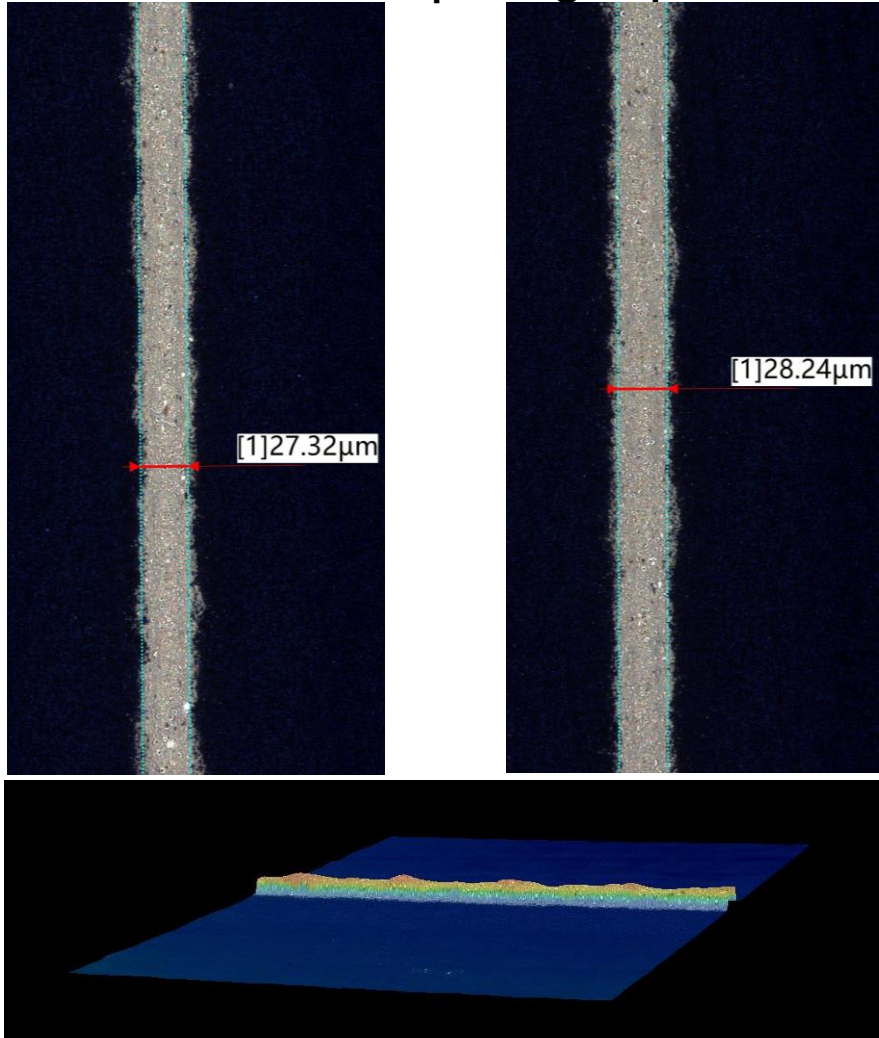


XRD pattern of silver-coated copper powder after calcination at different temperatures

LIN Jiali ZHANG Ying; CAO Mei ; GONG. Effect of calcination temperature on properties of electroless silver-plated copper particles Electroplating & Finishing. 2020(19) :1348-1351

Silver coated copper finger paste

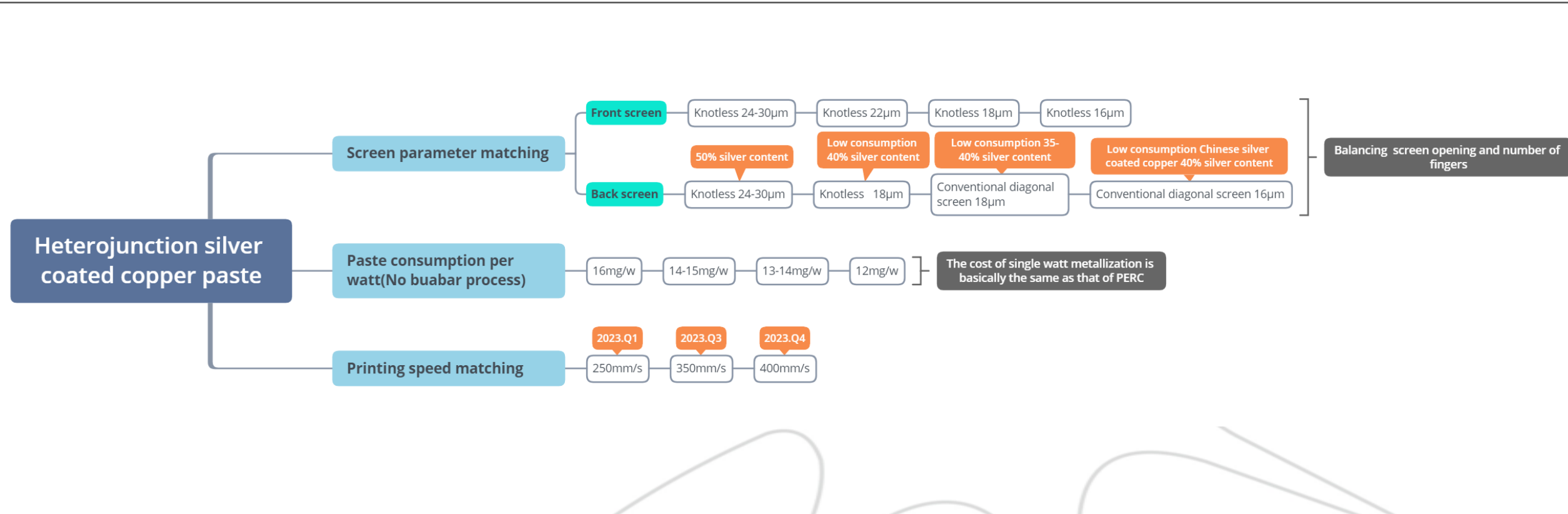
520/11 PI knotless/opening 18μm



	HAC639-T (Currently import)	HAC689-T (Next import)
Silver content (%)	43-50	30-40
Volume resistivity (μΩ.cm)	7.0-8.5	7.5-9.0
Printing speed (mm/s)	≥300	≥300

- The 50% silver coated copper fine grid paste has been used in several demonstration power stations with no abnormal power generation.
- 50% Ag silver coated copper fine grid paste has been mass produced.
- **Back 37% silver containing fine grid paste + Front 50% silver containing finger paste**, the efficiency is the same as that of sterling silver production line, and the metallization cost is greatly reduced.

Silver coated copper paste matching “No busbar” process





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Thanks for you attention!

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